NCCAVS
CMP USER GROUP
(www.avsusergroups.org)

FREE ADMISSION—No need to register, just show up!!

Topic: Advances in CMP Consumables

Sponsored By: Victrex USA

Meeting Date: MAY 16, 2012

Start Time: 2:00 – 5:00pm

Location: SEMI Global Headquarters
Seminar rooms 1 & 2
3081 Zanker Road
San Jose, CA 95134
Park in front or behind the vacant building across from SEMI

Co-Chairs:
Ashwani Rawat, Intel, ashwani.k.rawat@intel.com
Rob Rhoades, Entrepix, rrhoades@entrepix.com

TENTATIVE AGENDA

"The Sampling Statistics of Low Slurry Particle Counts", Michael Fury, Vantage Technology

"Tackling Critical Requirements for Advanced Post-CMP Cleans", Paul Bernatis, EKC

"Front-end, back-end and substrate slurries: Key process data", John Mendonca, Asahi Glass Corp.

"Advances in optical polishing abrasives and slurries", Floyd McClung, CV Nanotechnology

******Sponsorship Opportunities******
To sponsor this event, please contact Heather Korff at heather@avs.org.